Investigation of the process of spreading of a liquid droplet deposited on a substrate surface

S.A. Borodin^{1,2}

¹ Image Processing Systems Institute of RAS ² Samara State Aerospace University named after academician S.P. Korolev

Abstract

This paper proposes a model of the process of spreading of a liquid droplet on a substrate surface, based on the balance of the potential energy of a falling drop, the surface-tension energy, and the binding energy of molecules in liquids and solids. The experimental dependences of the droplet base radius and the duration of the spreading process on the degree of purity and roughness of the substrate surface purified by plasma-chemical etching coincide adequately with the calculated dependences.

<u>Keywords</u>: spreading of a liquid, energy of a falling drop, molecules, plasma-chemical etching.

<u>Citation</u>: Borodin SA. Investigation of the process of spreading of a liquid droplet deposited on a substrate surface. Computer Optics 2005; 28: 66-68.

Access full text (in Russian)

References

- [1] Adamson AW, Gast AP. Physical chemistry of surfaces. 6th ed. New York: John Wiley and Sons Inc; 1997.
- [2] Matveev AN. Molecular physics. Moscow: Mir Publishers; 1985.
- [3] Zangwill A. Physics at surfaces. Cambridge: Cambridge University Press, 1988.
- [4] Geguzin YE. Bubbles [In Russian]. Moscow: "Nauka" Publisher; 1985.
- [5] Yavorsky BM, Detlaf AA. Handbook of Physics. 3rd ed. Moscow: Mir Publishers; 1970.
- [6] Mishchenko KP, Ravdel AA. Short handbook of physicochemical quantities [In Russian]. Leningrad: "Himiya" Publihers; 1974.